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9/27/02

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re Application of: Kuei-Jen Chang

Group Art Unit: 1763

Serial No.: 09/ 822,749

Examiner: Mulero Alejandro

Filed: March 30, 2001

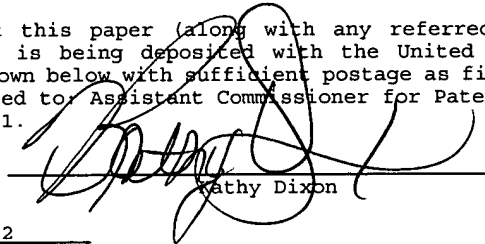
In Response to Office Action  
Dated: August 20, 2002

For: Method And Apparatus for In-Situ Descum/Hot Bake/  
Dry Etch Photoresist/Polyimide Layer

Attorney Docket No.: 67,200-397

Certificate of Mailing

I hereby certify that this paper (along with any referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231.

  
Kathy Dixon

Date: Sept. 20, 2002

RESPONSE TO OFFICE ACTION

Assistant Commissioner  
for Patents  
Washington, D.C. 20231


RECEIVED  
SEP 27 2002  
TO 1763 ART. ROOM

Dear Sir:

In response to an Office Action mailed August 20, 2002 of a restriction requirement imposed by the Examiner, the Applicants hereby elect with traverse the prosecution of Group I, method claims (claims 1-10).

Respectfully submitted,

Tung & Associates

  
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Randy W. Tung  
Reg. No. 31,311  
Telephone: (248) 540-4040